•	Application No.	Applicant(s)
Notice of Allowability	09/918,257	GRETTON ET AL.
	Examiner	Art Unit
	Martin J Angebranndt	1756
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	6 (OR REMAINS) CLOSED in this a ) or other appropriate communication RIGHTS. This application is subject	pplication. If not included on will be mailed in due course. <b>THIS</b>
1. This communication is responsive to <u>7/26/2004</u> .		
2. The allowed claim(s) is/are 1,3-13 and 24-41.		
3. $\boxtimes$ The drawings filed on $\underline{7/30/2001}$ are accepted by the Example 1.	miner.	
<ol> <li>Acknowledgment is made of a claim for foreign priority u         <ul> <li>a) ☐ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☐ Certified copies of the priority documents have</li> <li>2. ☐ Certified copies of the priority documents have</li> <li>3. ☐ Copies of the certified copies of the priority documents have a longer of the longer of the lo</li></ul></li></ol>	e been received. e been received in Application No.	
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a replement of this application.	y complying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXAMINE es reason(s) why the oath or declar	R'S AMENDMENT or NOTICE OF ration is deficient.
<ol> <li>CORRECTED DRAWINGS ( as "replacement sheets") mu</li> <li>(a) including changes required by the Notice of Draftspers</li> <li>1) hereto or 2) to Paper No./Mail Date</li> <li>(b) including changes required by the attached Examiner Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the state of the sheet in the same of the sheet.</li> </ol>	son's Patent Drawing Review(PTC - 's Amendment / Comment or in the	Office action of
<ol> <li>DEPOSIT OF and/or INFORMATION about the depo- attached Examiner's comment regarding REQUIREMENT</li> </ol>	osit of BIOLOGICAL MATERIAL FOR THE DEPOSIT OF BIOLOGIC	must be submitted. Note the CAL MATERIAL.
<ul> <li>Attachment(s)</li> <li>1. ☑ Notice of References Cited (PTO-892)</li> <li>2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date</li></ul>	6. ☐ Interview Summar Paper No./Mail Da 08), 7. ⊠ Examiner's Amend	ate
		Primary Éxaminer Art Unit: 1756

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1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Maurice Klee (30,399) on August 9, 2004.

The application has been amended as follows:

In claim 1, at line 7, after "the photoresist", please insert - - of less than the transverse size of any of the microlenses being formed - -.

In claim 30, at line 7, after "the photoresist", please insert - - of less than the transverse size of any of the microlenses being formed - -.

In claim 34, at line 7, after "the photoresist", please insert - - of less than the transverse size of any of the microlenses being formed - -.

In claim 38 at line 7, after "the photoresist", please insert - - of less than the transverse size of any of the microlenses being formed - -.

2. The following is an examiner's statement of reasons for allowance: The declaration evidence is convincing that both sharper features between the microlenses and most surprisingly increased smoothness in the resulting microlens surfaces due to the use of the larger laser beam and the formation of concave microlens profiles in the positive photoresist. There is motivation to form the lens with a tool (mechanical or shaped beam), which duplicates the profile of the desired microlens, but there is no motivation to use larger beams, which are less than the size of the feature produced as recited in the claims. The examiner notes that the applicant has a basis

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for the language describing the relative sizes of the beam and the transverse dimension of the lens in figures 3 and 5B of the instant application and also through reference to copending application 60/222,033.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J Angebranndt whose telephone number is 571-272-1378.
The examiner can normally be reached on Monday-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Martin J Angebranndt Primary Examiner

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